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APPLICATION NO.	FILING DATE	FIRST NAMED INVENTOR	ATTORNEY DOCKET NO.	CONFIRMATION NO.		
09/651,783 08/30/2000		Shuichi Kanno	NIP-198	2461		
24956	7590 03/27/2006		EXAM	EXAMINER		
	Y, STANGER, MALUR	NGUYEN, NO	NGUYEN, NGOC YEN M			
1800 DIAGONAL ROAD SUITE 370		ART UNIT	PAPER NUMBER			
ALEXANDRI	A. VA 22314	1754				

DATE MAILED: 03/27/2006

Please find below and/or attached an Office communication concerning this application or proceeding.

Cuy

			Application No.	Applicant(s)				
Office Action Summary		09/651,783	KANNO ET AL.					
			Examiner	Art Unit				
		_	Ngoc-Yen M. Nguyen	1754				
The MAILING DATE of this communication appears on the cover sheet with the correspondence address Period for Reply								
A SHORTENED STATUTORY PERIOD FOR REPLY IS SET TO EXPIRE 3 MONTH(S) OR THIRTY (30) DAYS, WHICHEVER IS LONGER, FROM THE MAILING DATE OF THIS COMMUNICATION. - Extensions of time may be available under the provisions of 37 CFR 1.136(a). In no event, however, may a reply be timely filed after SIX (6) MONTHS from the mailing date of this communication. - If NO period for reply is specified above, the maximum statutory period will apply and will expire SIX (6) MONTHS from the mailing date of this communication. - Failure to reply within the set or extended period for reply will, by statute, cause the application to become ABANDONED (35 U.S.C. § 133). Any reply received by the Office later than three months after the mailing date of this communication, even if timely filed, may reduce any earned patent term adjustment. See 37 CFR 1.704(b).								
Status								
1)⊠)⊠ Responsive to communication(s) filed on <u>06 March 2006</u> .							
	·		action is non-final.					
3)	Since this application is in condition	Since this application is in condition for allowance except for formal matters, prosecution as to the merits is						
	closed in accordance with the practice under Ex parte Quayle, 1935 C.D. 11, 453 O.G. 213.							
Disposition of Claims								
4)⊠	Claim(s) 3,4,11-14,16 and 17 is/are	pending in	the application.	•				
4a) Of the above claim(s) is/are withdrawn from consideration.								
5)	5) Claim(s) is/are allowed.							
6)⊠	6)⊠ Claim(s) <u>3,4,11-14,16 and 17</u> is/are rejected.							
7)	Claim(s) is/are objected to.							
8)[Claim(s) are subject to restrict	ction and/or	election requirement.					
Application Papers								
9)[The specification is objected to by th	e Examiner						
10)	The drawing(s) filed on is/are	: a) <u></u> acce	pted or b) objected to by the	Examiner.				
Applicant may not request that any objection to the drawing(s) be held in abeyance. See 37 CFR 1.85(a).								
Replacement drawing sheet(s) including the correction is required if the drawing(s) is objected to. See 37 CFR 1.121(d).								
11) The oath or declaration is objected to by the Examiner. Note the attached Office Action or form PTO-152.								
Priority under 35 U.S.C. § 119								
12) Acknowledgment is made of a claim for foreign priority under 35 U.S.C. § 119(a)-(d) or (f). a) All b) Some * c) None of:								
1. Certified copies of the priority documents have been received.								
2. Certified copies of the priority documents have been received in Application No								
3. Copies of the certified copies of the priority documents have been received in this National Stage								
application from the International Bureau (PCT Rule 17.2(a)).								
* See the attached detailed Office action for a list of the certified copies not received.								
Attachment(s)								
1) Notice of References Cited (PTO-892) 4) Interview Summary (PTO-413)								
				ate Patent Application (PT)	O-152)			
	nation Disclosure Statement(s) (PTO-1449 or r No(s)/Mail Date	L10/2R/08)	6) Other:	work reprised to the	J 192)			

DETAILED ACTION

A request for continued examination under 37 CFR 1.114, including the fee set forth in 37 CFR 1.17(e), was filed in this application after final rejection. Since this application is eligible for continued examination under 37 CFR 1.114, and the fee set forth in 37 CFR 1.17(e) has been timely paid, the finality of the previous Office action has been withdrawn pursuant to 37 CFR 1.114. Applicant's submission filed on March 6, 2006 has been entered.

The following is a quotation of the first paragraph of 35 U.S.C. 112:

The specification shall contain a written description of the invention, and of the manner and process of making and using it, in such full, clear, concise, and exact terms as to enable any person skilled in the art to which it pertains, or with which it is most nearly connected, to make and use the same and shall set forth the best mode contemplated by the inventor of carrying out his invention.

Claims 3-4, 11-14, 16-17 are rejected under 35 U.S.C. 112, first paragraph, as failing to comply with the written description requirement. The claim(s) contains subject matter which was not described in the specification in such a way as to reasonably convey to one skilled in the relevant art that the inventor(s), at the time the application was filed, had possession of the claimed invention.

Applicants are requested to point out support in the instant specification, by page and line numbers, for the limitations "wherein said step of removing mist is performed ... in said exhausting step" as required in the instant claims 3-4, 11, 13, 17. Applicants point out that support for the limitation "wherein said step of removing mist...in said

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exhausting gas" can be found on page 5, line 10 to page 6, line 14 of the instant specification and Figures 2(A) and 2 (B). Such disclosure in the specification may provide sufficient support for the claimed limitation when the "mist removal means" is cyclone mist separator as shown in Figures 2(A) and 2(B), but not for the generic "mist removal means" as required in Applicants' claims because the claimed "mist removal means" can be a filter mist separator (as shown in Figure 3) or electric dust collector (Figure 4). There is no disclosure in the instant specification or in Figures 3-4 that there were 2 liquid outlets for the filter mist generator or the electric dust generator.

Applicants are also requested to point out support in the instant specification, by page and line numbers, for the limitation of "decomposing a toxic component produced by said decomposition of PFC ... at the rear stage of said PFC decomposition process". It should be noted that in the instant specification, it is disclosed that SF₆ and NF₃ are decomposed into SO₃, HF, NO, NO₂ (note equation 1 and 2 on page 4) and these decomposition products "can be removed from the decomposed gas by washing with water or an alkaline aqueous solution" (note page 4, lines 11-13). Also, on page 12 of the instant specification, it is disclosed that PCF decomposition catalyst 8 and hazardous component removing catalyst 9 are packed into the PFC decomposition tower 1 and the hazardous component here means CO, SO₂F₂, and the like (note page 12, lines 3-8 and page 14, lines 18-25 which mention "SO₂F₂ decomposition catalyst"). There is no disclosure in the instant specification to indicate that the "decomposition products" from decomposing PFC and the "hazardous component" are the same. There

is no support in the instant specification for the two-step decomposing process as now required in the instant claims.

The following is a quotation of 35 U.S.C. 103(a) which forms the basis for all obviousness rejections set forth in this Office action:

(a) A patent may not be obtained though the invention is not identically disclosed or described as set forth in section 102 of this title, if the differences between the subject matter sought to be patented and the prior art are such that the subject matter as a whole would have been obvious at the time the invention was made to a person having ordinary skill in the art to which said subject matter pertains. Patentability shall not be negatived by the manner in which the invention was made.

Claims 3-4, 11-14, 16-17 are rejected under 35 U.S.C. 103(a) as being unpatentable over EP 0 885 648 in view of either JP 11-216,455 or Lang et al (6,235,256).

EP '648 discloses a process for decomposing fluorine compounds, comprising the steps of contacting a gas flow containing the fluorine compounds, which comprises fluorine as a halogen element, and any of the elements carbon, nitrogen and sulfur as a compound with the fluorine, with a fluorine compound-decomposition catalyst in the presence of steam to hydrolyze the fluorine compound in said gas flow, wherein said gas flow containing said fluorine compounds is contacted with a catalyst comprising AI to convert said fluorine compounds to hydrogen fluoride (note claim 1). In the equation 4 and 5 on page 3 of EP '648, when SF₆ or NF₃ is being decomposed, SO₃ or NO is formed. In the embodiments 6 and 7, SF₆ or NF₃ is diluted with air or nitrogen, the resulting gas is contacted with a catalyst to decompose the fluorine compound. The decomposed gas is scrubbed in an alkaline scrubber (note page 10, lines 1-25).

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EP '648 discloses that sulfur oxides such as SO₂, SO₃ and the like, and nitrogen oxides, such as NO, NO₂, and the like, are generated in some cases. In order to neutralize and eliminate these products, a method of scrubbing the decomposed gas by spraying an aqueous alkaline solution is desirable (note paragraph bridging pages 3-4). Thus, the scrubbing step is considered as the step of removing SO_x and NO_x from the washed gas.

For the second "decomposing" step, i.e. "decomposing a toxic component...at the rear stage of said PFC decomposing process", this claim is read in light of the specification that there are two separate catalysts, i.e. catalyst "8" and catalyst "9", to remove different components in the PFC gas simultaneously in a single process step (note instant specification, page 14, under "(Embodiment 1)". EP '648 discloses that the stream to be treated can contain more than one fluorine compound and the catalyst can contains at least one element selected from the group consisting of Zn, Ni, Ti, Fe, Sn, Pt, Co, Zr, Ce, and Si in additional to Al (note page 3, lines 8-15). Thus, when more than 1 element was used in addition to Al, the first element with Al is considered as the claimed "decomposition catalyst" and the second element with Al is considered as the claimed "toxic component decomposition catalyst".

The difference is EP '648 does not disclose the step of removing SO_x or NO_x from the decomposed gas after scrubbing by passing the gas after the scrubbing step through a cyclone or demister.

JP '455 discloses a process for treating an exhaust gas generated in a process of making printed circuit board by passing the exhaust gas through a catalytic thermal

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decomposition device 4 and the waste gas cleaning device 5 and discharged as a harmless exhaust gas 6 (note English abstract). As shown in Figure 3, the exhaust gas after scrubber 5 is introduced into a cyclone 8. Here the moisture within the exhaust gas is removed and recycled back to the scrubber 5 thereby minimizes the requirement of fresh scrubbing liquid. JP '455 further teaches that a demister can be used instead of a cyclone (note paragraph 0036).

For the limitation of "the removed mist is then drained through a liquid waste outlet... in the emission said of said gas exhausted in said exhausting step", since JP '455 desires to recycle the moisture back to be used as scrubbing liquid, it would have been obvious to one skilled in the art to recover such moisture in the form of a liquid and it would also have been obvious to one skilled in the art to repeat the moisture removing step and to select proper equipment to effectively recover and recycle as much as possible of the moisture in the exhaust gas.

For the instant claim 16, it would have been obvious to one of skill in the art to optimize the inlet velocity to effectively remove the moisture from the exhaust gas and to select an appropriate material for the construction of the cyclone to withstand the condition of the process.

It would have been obvious to one of ordinary skill in the art at the time of the invention was made to pass the exhaust gas after the scrubbing step in EP '648 to a cyclone or demister, as suggested by JP '455, because by doing so, the moisture can be removed from the gas and recycled to the scrubber thereby minimizes the

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requirement of fresh scrubbing liquid. Such step would inherently remove any remaining NO_x or SO_x from the washed gas.

Alternatively, Lang '256 can be applied. Lang '256 discloses a process for scrubbing acid gases. In the process, the improvement is a demister arranged at a location after the liquid droplets have been sprayed by the spray means into the flow path of the flue gases (note column 3, lines 8-43 and claim 1).

It would have been obvious to one of ordinary skill in the art at the time of the invention was made to pass the exhaust gas of EP '648 to a demister, as suggested by Lang '256 in order to obtain the advantages as disclosed in Lang '256 (note, for example, column 1, lines 44-50).

Claims 3-4, 11-14, 16-17 are rejected under 35 U.S.C. 103(a) as being unpatentable over Kanno et al (PGPub US 2001/0001652) in view either JP 11-216,455 or Lang et al (6,235,256).

Kanno '652 is an US counterpart of EP '648.

Kanno '652 discloses a process as mentioned for EP '648 (note claim 1, Examples 11-12).

The difference is Kanno '652 does not disclose the step of removing NO_x or SO_x after the scrubbing steps.

JP '455 or Lang is applied to teach the step of passing the gas after the scrubbing step to a cyclone or demister.

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Applicant's arguments filed March 6, 2006 have been fully considered but they are not persuasive.

The 112, first paragraph rejection for "wherein said step of removing mist... in said exhausting steps" is maintained for the reasons stated in the rejection above.

Applicants argue that a significant feature in the claimed invention is to remove decomposition products through "two state" of treatments.

The combined teaching of the applied references fairly suggests a process for first removing the decomposition product from a gas by washing and then by passing the resulting gas through a demister as required by Applicants' claims.

The rejections are maintained for the same reasons as stated above.

The prior art made of record and not relied upon is considered pertinent to applicant's disclosure.

Any inquiry concerning this communication or earlier communications from the examiner should be directed to Ngoc-Yen M. Nguyen whose telephone number is (571) 272-1356. The examiner is currently on Part time schedule.

If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, Mr. Stanley Silverman can be reached on (571) 272-1358. The fax phone numbers for the organization where this application or proceeding is assigned are (703) 872-9306 or (571) 273-8300.

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Any inquiry of a general nature or relating to the status of this application or proceeding should be directed (571) 272-1700.

Ngoc-Yen M. Nguyen Primary Examiner Art Unit 1754

nmn March 17, 2006